Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	213	(absorbing or absorption or antireflective or arl or arc or antireflection or anti-reflective or anti-reflection or absorptive or absorbant) near10 (graphite) near10 (laser or krf or excimer or ablation or ablating)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:21
L2	1	laser near2 (patterning or patterned or structuring) near10 graphite	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:22
L3	224	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) and (arc or coating or arl or coated) near5 graphite	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:23
L4	78	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) and (arc or coating or arl or coated) near5 graphite and (krf or excimer or ultraviolet or uv)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:30
L5	144	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) and (arc or coating or arl or coated) near5 (carbon adj black) and (krf or excimer or ultraviolet or uv)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:31
L6	0	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) near10 (cathode or anode or electrode) and (cathode or anode or electrode) near5 (coated or coating or covered or covering or antireflective or anti-reflection or anti-reflection or antireflecting or anti-reflecting or arti-reflecting	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:32
L7	0	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) near10 (cathode or anode or electrode) and (cathode or anode or electrode) near5 (absorbing or absorptive or absorbed or absorption) near8 (carbon adj black)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:36
L8	198	(laser or beam) near2 (absorption or absorptive or absorbing) near5 (graphite or carbon adj black)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 09:36
S1	41	(oled or o-led or organic near light near2 diode) and (electrode or ito or anode or cathode) near7 (ablation or ablated or ablating or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/10 08:52
S2	501	(strip or stripe or striped or bar or linear) near4 (electrode or ito or anode or cathode) near7 (ablation or ablated or ablating or ablate or removal or (laser or electrode or metal) near2 (removing or removal or removed or remove))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/07 10:23
S3	168	(strip or stripe or striped or bar or linear) near4 (electrode or ito or anode or cathode) near7 (ablation or ablated or ablating or ablate or removal or (laser or electrode or metal) near2 (removing or removal or removed or remove)) and (led or light near2 emitting or electroluminescent or display or pixel)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/07 10:31
S4	240	(electrode) near3 (patterning or patterned) near6 (laser or ablation or ablating or ablated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/07 10:32

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S5	157	(cathode or anode or electrode) near3 (periodic or grating or striped or stripe or strip or bar) same (laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/07 14:26
S6	308	· (laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate) same (optical or light or beam or laser) near3 (expander or expansion or expanding or expanded or expand or elongate or elongated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/07 14:27
S7	9	(US-20020058420-\$ or US-20020196401-\$ or US-20030134506-\$ or US-20030186078-\$ or US-20040149986-\$ or US-20050007645-\$).did. or (US-6146715-\$ or US-6376799-\$ or US-6719916-\$).did.	US-PGPUB; USPAT	OR	ON	2005/03/07 15:17
S8	174	(electrode or ito ro anode or cathode) near8 ("2d" or "1d" or two adj dimensional or two adj dimension or one adj dimension or line) near3 (ablation or ablating or ablate or ablated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 10:07
S9	558	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (laser) near2 (ablation or ablating or ablated or ablate or etching or etched or etch or cutting or cut)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 10:10
S10	88	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (laser) near2 (ablation or ablating or ablated or ablate or etching or etched or etch or cutting or cut) near8 (electrode or ito or anode or cathode)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08.14:45
S11	6	("4490211" "4879449" "5514618" "5536579" "5766497" "5841099").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/08 13:45
S12	12	("4117177" "4617085" "4652462" "5281450" "5302423" "5314709" "5340619" "5386430" "5693962" "5701055" "5824374" "5953585").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/08 13:46
S13	0	("6146715").URPN.	USPAT	OR	ON	2005/03/08 13:55
S14	12	("5514618").URPN.	USPAT	OR	ON	2005/03/08 14:04
S15	36	shimo.in. and nobuo.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:41
S16	189	(laser) near2 (ablation or ablating or ablated or ablate) same (exhaust or outlet or vent) .	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:42
S17	. 35	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (laser) near2 (ablation or ablating or ablated or ablate or etching or etched or etch or cutting or cut) and (exhaust or vent or venting or outlet)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 15:57
S18	14	•	US-PGPUB; USPAT; JPO	OR	ON	2005/03/08 15:44
S20	3	((US-20020058420-\$ or US-20020196401-\$ or US-20030134506-\$ or US-20030186078-\$ or US-20040149986-\$ or US-20050007645-\$ or US-20020187594-\$).did. or (US-6146715-\$ or US-6376799-\$ or US-6433489-\$ or US-6719916-\$ or US-5514618-\$).did. or (JP-08222371-\$ or JP-2004140003-\$).did.) and (exhaust or outlet or vent or venting)	US-PGPUB; USPAT; JPO	OR	ON	2005/03/08 15:51

S21	60	laser near3 (ablation or ablating or ablated) near5 (outlet or exhaust or vent or venting)	US-PGPUB; USPAT; JPO	OR	ON	2005/03/08 15:51
S22	1	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (etch or etching or etched) near5 (exhaust or vent or outlet)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 15:58
S23	27	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (etch or etching or etched or ablation or ablating or removal or removing) near10 (exhaust or vent or outlet)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 16:02
S24	4	(oled or o-led or organic near led or organic near light near emitting or oel or organic near electroluminescent or o-el) and (laser) near3 (ablation or ablating or ablate or ablated or removal or removing or etching or etch or etched) near15 (graphite)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 16:03
\$25	188	(laser) near3 (ablation or ablating or ablate or ablated or removal or removing or etching or etch or etched) near15 (graphite)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON .	2005/03/08 16:42
S26	3	krf near6 (graphite)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 16:43
S27	42	(krf or kr adj f or excimer) near10 (graphite) .	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 16:43